JPA1975-127647 applied on Oct 23, 1975

Inventor Yoshiaki Hagiwara at Sony

First N+N-P+N junction Type
Pinned Buried Photodiode
with the MOS/CCD Capacitor Type
Global Shutter Buffer Memory
and P+ Buried Photo Charge Storage
with Completely Empty Potential Well
and Pinned N+N type Surface with Metal Contact
with Zero RC delay time constant
for high frequency electric shutter function.

公開特許公報

①特開昭 52-51816

43公開日 昭52.(1977) 4.26

②特願昭 50-127647

②出願日 昭加.(1975/10.23

審查請求 未請求

(全6頁)

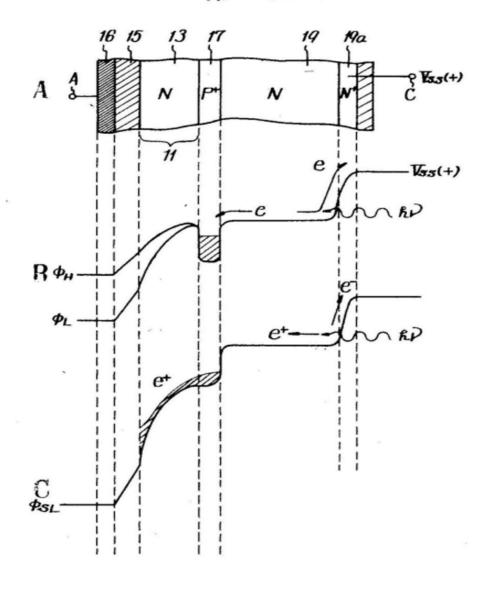


Figure 7 of JPA1975-127647